

| L Number | Hits | Search Text | DB | Time stamp |
|----------|------|---|----------------------------------|------------------|
| 1 | 0 | ((silicon near3 nitride) Si3N4 ("Si.sub3" adj "N.sub.5")) near50 (wet clean\$3 treat\$3) near50 ((carbon near5 water) (((CO2 "CO.sub.2") (carbon near3 dioxide)) near5 (water H2O ("H.sub.2" adj "O"))))) | USPAT; US-PGPUB | 2003/08/08 09:22 |
| 2 | 12 | ((silicon near3 nitride) Si3N4 ("Si.sub3" adj "N.sub.5")) same (wet clean\$3 treat\$3) same ((carbon near5 water) (((CO2 "CO.sub.2") (carbon near3 dioxide)) near5 (water H2O ("H.sub.2" adj "O"))))) | USPAT; US-PGPUB | 2003/08/08 09:25 |
| 3 | 3 | ((silicon near3 nitride) Si3N4 ("Si.sub3" adj "N.sub.5")) same (wet clean\$3 treat\$3) same ((carbon near5 water) (((CO2 "CO.sub.2") (carbon near3 dioxide)) near5 (water H2O ("H.sub.2" adj "O"))))) | EPO; JPO; DERWENT; IBM_TDB | 2003/08/08 09:25 |